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2 **Supplementary Information for**

3 **A symmetry-derived mechanism for atomic resolution imaging**

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6 **This PDF file includes:**

- 7 Supplementary text
- 8 Figs. S1 to S6
- 9 Legends for Movies S1 to S2
- 10 SI References

11 **Other supplementary materials for this manuscript include the following:**

- 12 Movies S1 to S2

13 Supporting Information Text

14 §1. Notes on Symmetry STEM

15 Intensity I in S-STEM is defined by:

$$16 \quad I = \max \left[\mathbf{A} * \underset{\text{operation}}{\text{symmetry}} (\mathbf{A}) \right], \quad [1]$$

17 where $*$ is a normalised cross-correlation and the symmetry operation can be chosen (a rotation or a mirror). If \mathbf{A} is invariant
18 under the symmetry operation, then the intensity will be maximum, $I = 1$, and $I < 1$ if symmetry is not matched. This
19 operation is applied to the recorded scattered electron intensity for each point of a scan. In calculating S-STEM images the
20 following points are worth noting:

- 21 • Unlike traditional STEM, in S-STEM the CBED pattern does not need to be centred on the detector, because the
22 intensity is based on a maximum value of the cross-correlation and it is therefore shift invariant (1).
- 23 • The result of 0° rotation (identity) will always be $I = 1$ due to Eq. 1 becoming an auto-correlation. Due to the presence
24 of noise in any real image and due to interpolation errors in the image rotation algorithm, the symmetry value can only
25 be $I = 1$ in very specific cases: only if no interpolation is needed to perform the symmetry operation and the image
26 exactly matches the tested symmetry.

27 §2. Symmetry STEM dependence on electron beam energy and corresponding probe size

28 To investigate the dependence of symmetry-STEM contrast on the electron beam energy (and hence diffraction-limited probe
29 size), we have calculated intensity profiles for beam energies from 30 kV to 300 kV for a line scan over the Ce-B-Ce atomic
30 columns in $\langle 011 \rangle$ CeB₆ and a specimen thickness of 20 nm (Fig. S1a). We again chose the symmetry element of 180° rotation
31 and used the base parameters specified in Methods - STEM simulations unless otherwise noted.

32 As the beam energy is lowered from 300 kV to 30 kV, the diffraction-limited probe diameter increases by more than 3.5 times.
33 From 300 kV to just beyond 200 kV, a narrow intensity maxima at the Ce and B column positions persists with similar width
34 but then broadens as the probe size increases relative to the rate of change of the symmetry of the local specimen potential
35 (Fig. S1a).

36 To illustrate the reason for the relative stability of S-STEM contrast with respect to beam energy, we have extracted the
37 CBED patterns arising at 4 different beam energies (and 2 different probe positions) in Fig. S1b. These show that, although
38 the intensity distribution changes significantly with energy, its symmetry does not (as is well-known). Hence the primary
39 impact of changing accelerating voltage, is to change the diffraction-limited probe size and therefore the rate of change of
40 symmetry as the probe is scanned across the specimen. (Note that some tiny perturbations of symmetry in these calculations
41 are artefacts of pixelation.)

42 To highlight the reason for the sharp intensity maxima at atomic columns, we have also extracted the CBED patterns
43 arising when the probe is shifted just 0.15 \AA away from the centre of the atomic column (but still sits on the column), for each
44 of the above beam energies. The immediate loss of a symmetry element is evident in these patterns (most clearly at the higher
45 accelerating voltages and smaller probe sizes), giving rise to a rapid change in the corresponding S-STEM intensity and the
46 sharp intensity maxima.

47 §3. Symmetry STEM dependence on defocus and tilt for a thicker sample

48 To explore further the dependence of symmetry-STEM contrast on defocus and tilt, we have calculated additional intensity
49 profiles for a line scan over the Ce-B-Ce atomic columns in $\langle 011 \rangle$ CeB₆ for a specimen of 20 nm (Figs. S2a and b), thicker than
50 for Figure 4. We again chose the symmetry element of 180° rotation and used the base parameters specified in Methods -
51 STEM simulations unless otherwise noted. The results are consistent with the thinner specimen in Figure 4.

52 §4. Line scan comparison of Symmetry STEM with conventional STEM image modes

53 The comparison of Symmetry STEM with conventional STEM image modes in Fig. S3 illustrates that, in the absence of
54 instrument and specimen instability (collectively, ‘scan noise’), the Symmetry-STEM images show narrow intensity peaks and
55 relatively high and stable contrast with respect to defocus and thickness, compared with the conventional STEM imaging
56 modalities. Furthermore, the contrast is sensitive to, and generates local intensity peaks at, both heavy and light atomic
57 number atoms (Ce, $Z=58$ and B, $Z=5$). This illustrates the potential of Symmetry-STEM when executed on stable instruments
58 with fast detectors, such as are currently under development.

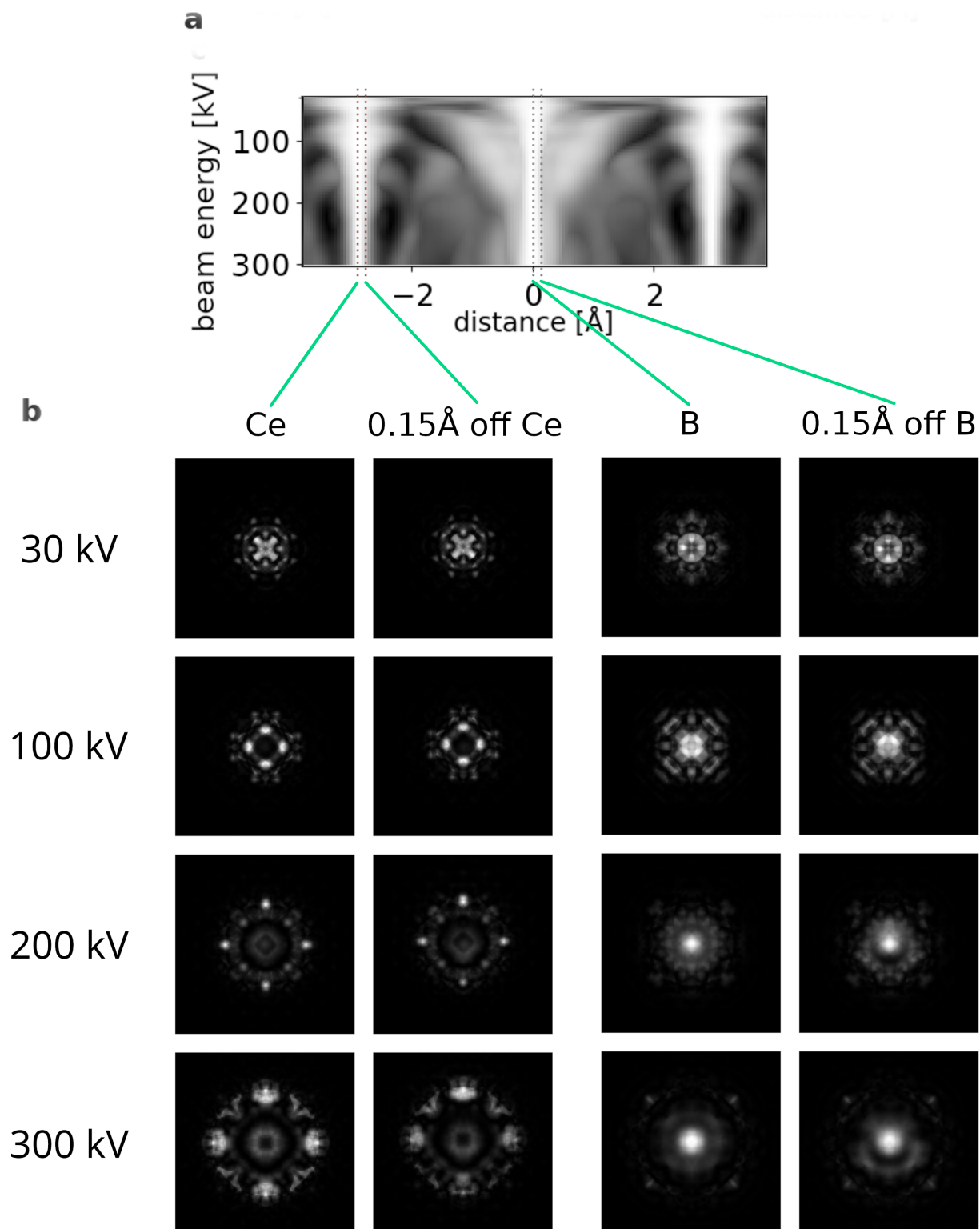


Fig. S1. Symmetry STEM intensity for a scan across Ce-B-Ce atoms along (011) . **(a)** Intensity versus electron energy (varied from 30kV to 300kV), **(b)** CBED patterns corresponding to **a** arising when the beam is centred on the Ce and B atomic columns and when it is shifted off-centre by 0.15 Å (but is still on the column).

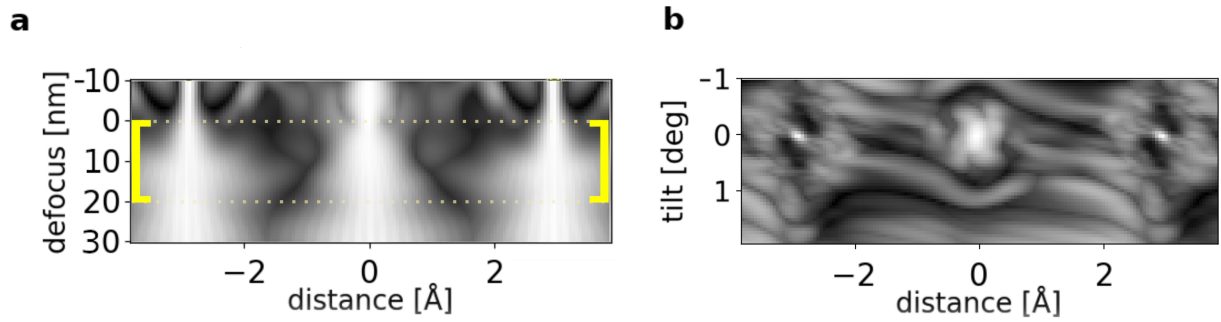


Fig. S2. Symmetry STEM intensity for a scan across Ce-B-Ce atoms along $\langle 011 \rangle$. **(a)** Intensity versus defocus (varied between -10nm to 30nm with the sample located at 0-20nm, see yellow markers). **(b)** Intensity versus tilt (varied between -1 and 2 degrees)

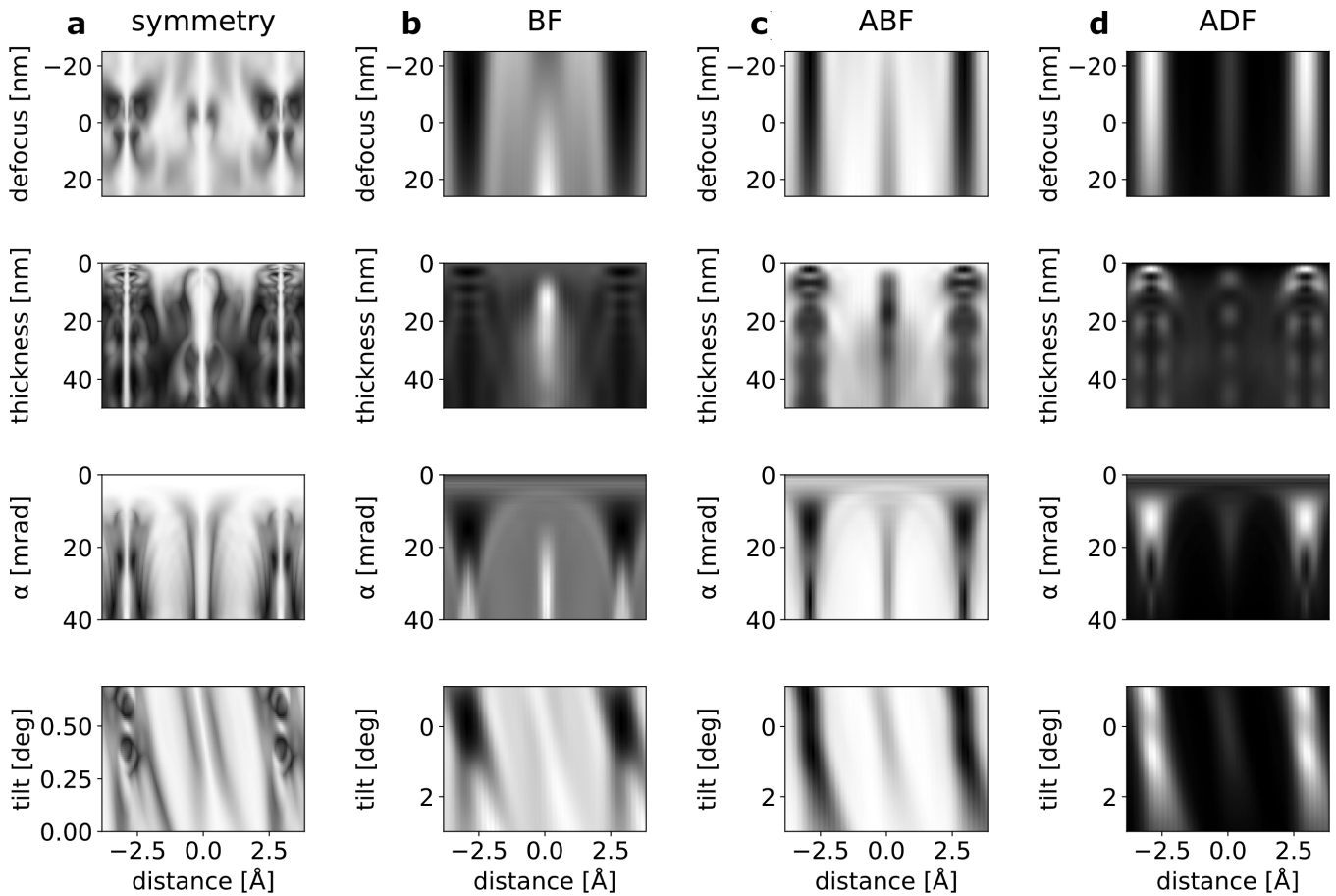


Fig. S3. Calculations of **(a)** Symmetry **(b)** BF **(c)** ABF and **(d)** ADF - STEM intensity for a $\langle 011 \rangle$ line scan over Ce-B-Ce atomic columns in $\langle 100 \rangle$ CeB_6 for different defocus and probe size and sample thickness and tilt using the same parameters as for Fig. 4 in the main text. In each graph, the signal has been internally normalised.

59 §5. Resolution in computational imaging

60 In their analysis of the concept of resolution in computational imaging, Paganin, Gureyev et al. (2, 3) have coined the term
61 “indirect” imaging system to refer to the many forms of imaging that involve a two-step approach, where the first step is
62 the recording of an experimental image and the second step is its computational reconstruction (2, 3). As these authors
63 note, in many indirect imaging systems, such as ptychography (4, 5), holography (6, 7), tomography (8) and super-resolution
64 fluorescence microscopy (9), the second step can significantly enhance the resolution of the final image. It is therefore not
65 necessarily meaningful to describe resolution here solely in terms of the resolution of the physical system that records the
66 initial experimental data (2, 3). Symmetry-STEM is also an ‘indirect’ imaging system in the sense that it involves two-steps;
67 (i) a direct physical system for acquiring electron diffraction patterns within which information about the specimen symmetry
68 is encoded, and (ii) a computational system which applies an algorithm to extract this information. Similar to the other
69 indirect systems noted above, the final image resolution is not determined solely by the operational parameters of the scanning
70 transmission electron microscope that recorded the initial data set. Indirect imaging systems can also improve the precision
71 with which information is extracted from the experimental data, such as peak fitting of atomic resolution images to identify
72 atomic positions (10).

73 §6. Poisson noise influence

74 Symmetry STEM will be influenced by the level of noise in 4D-STEM data. A model based on a simplified Poisson noise was
75 tested here, where noise with Gaussian distribution and standard deviation $\sigma = \sqrt{\text{mean disk signal}}$ was added to the data. The
76 influence of this noise distribution on the contrast in a single diffraction pattern can be seen in Fig. S4. We have compared the
77 raw dataset and the same data with simplified Poisson noise included in Fig. S5, where conventional STEM techniques are
78 compared with S-STEM. It is expected that the influence of the noise in conventional STEM will be averaged away because
79 the data is summed over corresponding areas in the diffraction space. In S-STEM (180° rotation), we can see that there is
80 some influence of the Poisson noise if Figs. S5d and i are compared. The main difference is a slightly lower contrast over the
81 atomic column signal, which can be expected due to lower symmetry maximum after the noise addition. The influence is small
82 because the noise would have to be correlated with the symmetry operation, which in this case it is not.

83 §7. Impact of phonon scattering on S-STEM contrast

84 Phonon scattering can generate an asymmetric intensity distribution in reciprocal space (but not real space (11)), which could
85 alter the intensity in a S-STEM image. We discuss the circumstance for which this might occur in this section.

86 Given S-STEM images are generated from the whole scattered intensity distribution (in so far as the detector size permits),
87 the relative intensity contribution from phonon scattering is very small (5 or 6 orders of magnitude) particularly at lower
88 scattering angles. In general, this means that phonon scattering will not have a significant impact on S-STEM contrast.
89 Exceptions to this statement will occur in materials with strong low frequency modes. This is evident when considering the
90 equation governing the kinematic scattering of high energy electrons from crystal phonons [see for example, (12)]:

$$91 \quad \mathbf{I}(\mathbf{s}) = \sum_{k,k'} \frac{g_k g_{k'}^*}{\sqrt{m_k m_{k'}}} \exp \{2\pi i \mathbf{s} \cdot (\mathbf{r}_k - \mathbf{r}_{k'})\} \times \sum_j \frac{E_j(\mathbf{q})}{[\nu_j(\mathbf{q})]^2} \{ \mathbf{s} \cdot \mathbf{U}_{kj}(\mathbf{q}) \} \{ \mathbf{s} \cdot \mathbf{U}_{k'j}^*(\mathbf{q}) \}, \quad [2]$$

$$92 \quad \mathbf{s} + \mathbf{q} = \mathbf{h}, \quad [3]$$

94 where m_k and g_k are respectively the mass and the atomic form factor corrected for the thermal motion of the k -th atom
95 in a unit cell; $\nu_j(\mathbf{q})$, $E_j(\mathbf{q})$ and $\mathbf{U}_{kj}(\mathbf{q})$ are respectively the frequency, the mean phonon energy and the polarisation vector
96 associated with the wave vector \mathbf{q} for the branch \mathbf{j} . The vector \mathbf{h} denotes the reciprocal lattice point nearest to the point \mathbf{s} .

97 This equation describes the geometry of phonon scattering to a good approximation (but not the quantitative intensity
98 distribution). It is evident from this equation that the intensity of phonon scattering is inversely proportional to the frequency
99 of the phonon mode. In most materials, the majority of modes are high frequency and will scatter weakly. Moreover, the sum
100 of the intensity distribution across all high frequency modes and their wave vectors will, to good approximation, generate a
101 weak, diffuse and spherically symmetric background intensity in the diffraction pattern. In other words, the sum over scattering
102 from all high frequency modes will not introduce a specific strong symmetry element into the diffraction pattern and hence
103 will not influence the S-STEM image contrast significantly. In contrast, the small number of low frequency modes can scatter
104 significant intensity. The angular distribution of this intensity is governed by the orientation of the phonon mode’s wave vector,
105 \mathbf{q} , relative to the scattering vector, \mathbf{s} (equation 2). Given there may only be three significant low frequency modes, the angular
106 distribution of scattering from these modes may dominate above the diffuse background from the high frequency modes, giving
107 non-spherically symmetric structure to the diffuse background. Classic examples are the non-radial diffuse streaks generated by
108 low frequency acoustic modes in materials such as silicon and aluminium (13). This intensity is still very weak compared with
109 the Bragg reflections and unlikely to have a significant impact. Nevertheless, it may be detectable with high-dynamic range
110 detectors, in which case S-STEM contrast could be slightly influenced by the symmetry element associated with the weak,
111 structured diffuse intensity distribution.

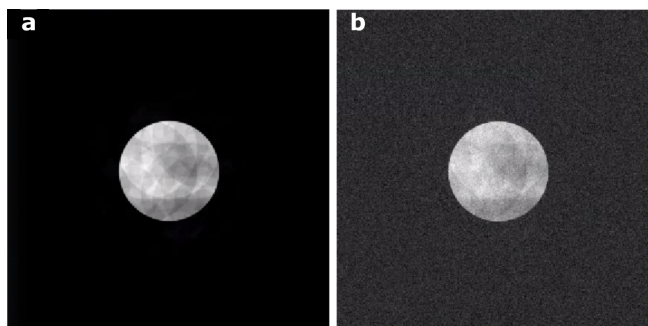


Fig. S4. Example of a diffraction pattern without noise (a) and with simplified Poisson model shot noise (b). The pattern was taken from the same 4D-STEM dataset as was analysed in Fig. 3. The convergence semi-angle was 15 mrad and acceleration voltage 300 kV.

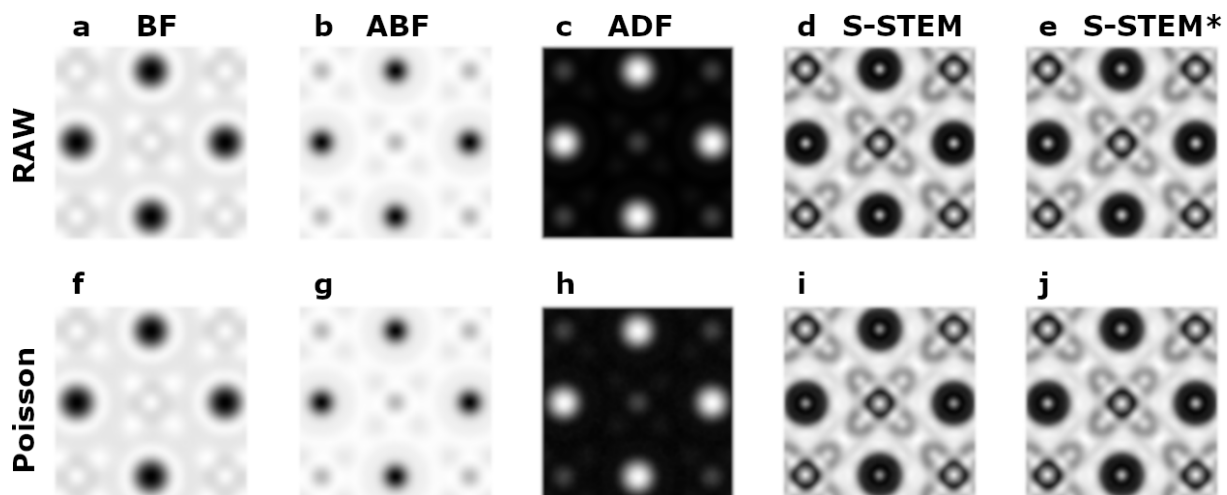


Fig. S5. Influence of simplified Poisson noise on resulting data for standard STEM imaging and S-STEM. First row shows an analysis without any noise for BF, ABF, ADF, S-STEM and S-STEM* in (a)-(e) respectively. Diffraction patterns in S-STEM* were smoothed by convolving with a Gaussian with sigma $\sigma = 1$ before the analysis. Second row, (f)-(j), shows the same analysis but with added Poisson like shot noise. The effect of Poisson noise on S-STEM is small but noticeable if **d** and **i** are compared - there is a reduction of contrast at Ce atomic sites in **i**. This effect can be minimised by smoothing the data before the processing, as can be seen in **j** for smoothed S-STEM*.

112 **§8. Impact of non-rotationally symmetric aberrations**

113 In this paper, we have explored the practical case, readily achievable in modern instruments, where there are minimal aberrations
114 within the angular range of the probe forming aperture. In the alternative case where significant aberrations are present in the
115 probe, they will be present at every point of the scan, irrespective of the specimen structure. This will contribute a constant
116 background to the corresponding S-STEM image, reducing contrast. The magnitude of this constant background depends on
117 the degree to which the symmetry of the aberration matches the chosen symmetry operation in equation (1) and could be
118 anything from zero to one. Indeed, the S-STEM image could be used to identify the presence of a significant aberration with a
119 given symmetry operation in the probe.

120 **§9. Additional experimental example - wedge-shaped sample**

121 In a wedge-shaped sample, the mirror symmetry in the CBED pattern will be broken perpendicular to the thickness gradient
122 due to the change in the number of atoms per atomic column, as highlighted in Fig. S6. This has potential for counting the
123 number of atoms in the atomic columns with high precision.

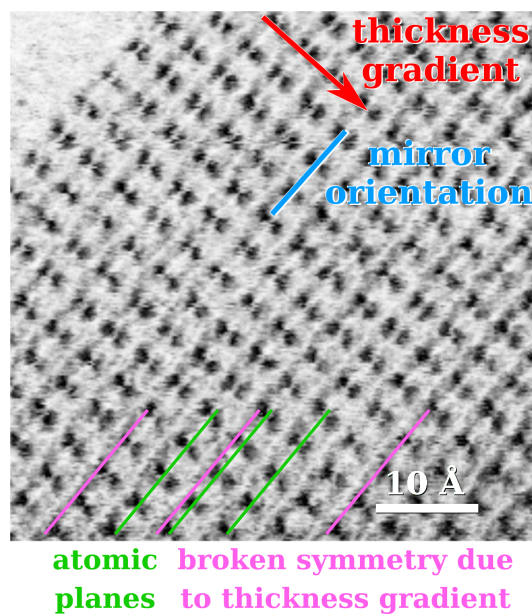


Fig. S6. Mirror Symmetry STEM image from an edge of the wedge-shaped CeB₆ sample. Inset shows that Symmetry STEM detects the break in symmetry due to the thickness gradient. The text shows details about thickness variation and the orientation of the chosen mirror symmetry used in the analysis. The convergence semi-angle was 15 mrad and acceleration voltage 300 kV.

124 **Movie S1. Animation of rotational symmetry analysis showing experimental S-STEM images between angles**
125 **1° to 180°. The field of view is $\sim 57 \times 57 \text{ \AA}$. The convergence semi-angle was 15 mrad and acceleration voltage**
126 **300 kV.**

127 **Movie S2. Animation of mirror symmetry analysis showing experimental S-STEM images between angles 1°**
128 **to 180°. The field of view is $\sim 57 \times 57 \text{ \AA}$. The convergence semi-angle was 15 mrad and acceleration voltage**
129 **300 kV.**

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